

	Hit s	Search Text	DBs
22	139	((first near4 (mask or reticle or phase\$3shift\$4mask or photomask)) same ((second or third or multiple) near5 (mask or reticle or phase\$3shift\$4mask or photomask))) and (first same (mask or reticle or photomask) same second same phase same (invers\$3 or revers\$3 or shift\$4) same (light or beam or radiation or illuminat\$4)) and (auxiliary or serif\$3 or dummy)	US-PPGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
23	113	((first near4 (mask or reticle or phase\$3shift\$4mask or photomask)) same ((second or third or multiple) near5 (mask or reticle or phase\$3shift\$4mask or photomask))) and (first same ((mask or reticle or photomask) near16 second) same phase same (invers\$3 or shift\$4) same (light or beam or radiation or illuminat\$4) same (expos\$4 or irradiat\$4 or illuminat\$4)) and (auxiliary or serif\$3 or dummy)	US-PPGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
24	27	((first near4 (mask or reticle or phase\$3shift\$4mask or photomask)) same (defect or error) same ((second or third or multiple) near5 (mask or reticle or phase\$3shift\$4mask or photomask))) and (first same ((mask or reticle or photomask) near16 second) same phase same (invers\$3 or shift\$4) same (light or beam or radiation or illuminat\$4) same (expos\$4 or irradiat\$4 or illuminat\$4)) and (auxiliary or serif\$3 or dummy)	US-PPGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

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25	6	((first near4 (mask or reticle or phase\$3shift\$4mask or photomask) near16 (defect or error)) same ((second or third or multiple) near5 (mask or reticle or phase\$3shift\$4mask or photomask) near16 (defect or error))) and (first same ((mask or reticle or photomask) near16 second) same phase same (invers\$3 or shift\$4) same (light or beam or radiation or illuminat\$4) same (expos\$4 or irradiat\$4 or illuminat\$4)) and (auxiliary or serif\$3 or dummy)	US - PGPUB
26	46	430/311.ccls. and ((first near4 (mask or reticle or phase\$3shift\$4mask or photomask) ) same ((second or third or multiple) near5 (mask or reticle or phase\$3shift\$4mask or photomask))) and (first same ((mask or reticle or photomask) near16 second) same phase same (invers\$3 or shift\$4) same (light or beam or radiation or illuminat\$4) same (expos\$4 or irradiat\$4 or illuminat\$4)) and (auxiliary or serif\$3 or dummy)	US - PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB